REEL: 014892 FRAME: 0553

CORPORATE ASSIGNMENT

WHEREAS, Arch Specialty Chemicals, Inc., a Delaware corporation, with its principal place of business at 501 Merritt 7, P.O. Box 5204, Norwalk, Connecticut 06856 (hereinafter referred to as "Assignor"), is the owner of inventions pertaining to the inventions that are fully described in attached Schedule A (hereinafter referred to as "the Patents and Patent Applications"); and

WHEREAS, Planar Solutions LLC, a Delaware corporation, with its principal place of business at 3301 Sutton Road, Adrain, Michigan 49221 (hereinafter referred to as "Assignee"), wishes to acquire the entire right, title and interest in and to the invention, as well as to the Patents and Patent Applications and all other corresponding foreign patent rights;

NOW THEREFORE, for valuable and legally sufficient considerations, receipt of which are hereby acknowledged, the Assignor sells, assigns and transfers to Assignee, its successors and assigns, the entire right, title and interest for the United States in and to the invention and the Patents and Patent Applications for the full term of any Letters Patent which issues therefrom:

The Assignor also sells, assigns and transfers to Assignee the entire right, title and interest in and to the invention and application for Letters Patent and Letters Patent therefor in all countries foreign to the United States, including all rights under the International Convention. The Assignor further authorizes Assignee to apply for Letters Patent in foreign countries in the name of the inventors who have previously assigned this right and this invention to Assignor, and to claim the priority of the filling date of the United States Application under the provisions of the International Convention;

The Assignor further agrees, for itself and its legal representatives, it will assist or direct the inventors to assist Assignee in the prosecution before the United States Patent Office and the Federal Courts of this application, and other applications for Letters Patent including renewals, continuations, continuation-in-parts, divisions, reissues and substitutions, that the Assignee elects to make covering the invention. The Assignor vests in Assignee like exclusive

PATENT REEL: 014892 FRAME: 0554 title in and to all such other applications and Letters Patent. The Assignor will execute or direct the inventors to execute and deliver to Assignee any documents which may be requested by Assignee to carry out the terms of this Assignment; and

The Commissioner of Patents and Trademarks of the United States is authorized and requested to issue Letters Patent of the United States to Assignee. The Assignor also authorizes and requests the equivalent authorities in foreign countries to issue the patents of foreign countries to Assignee.

IN WITNESS WHEREOF, Assigned				-	
	, 200			-	
				Arch S	pecialty Chemicals, Inc.
			Ву:		1. Llbuh
				Name: Title:	Philippe GOUBY President
STATE OF)	SS			
COUNTY OF)	33			
Sworn to and subscribed before i	me th	nis			day of
		, 2	2003.		
				Notary	Public



Edwin VAN LAETHEM, associate notary public at Ixelies (Brussels), hereby certifies that this (these)

is (are) the authentic signature(s) of Price por Goraly

Grand, 22 nd of December 2003

PATENT

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Country	Appin./Patent No.	Filing/Issue Date	Title
ns	09/845,549	April 30, 2001	CHEMICAL MECHANICAL POLISHING SLURRY COMPOSITION FOR POLISHING CONDUCTIVE AND NON-CONDUCTIVE LAYERS ON SEMICONDUCTOR WAFERS
SN	10/268,254	October 9, 2002	CHEMICAL MECHANICAL POLISHING SLURRY COMPOSITION FOR POLISHING CONDUCTIVE AND NON-CONDUCTIVE LAYERS ON SEMICONDUCTOR WAFERS
European	01922992.1	April 2, 2001	READY-TO-USE STABLE CHEMICAL- MECHANICAL POLISHING SLURRIES
Japan	2002-509430	April 2, 2001	READY-TO-USE STABLE CHEMICAL- MECHANICAL POLISHING SLURRIES
South Korea	1020037000216	April 2, 2001	READY-TO-USE STABLE CHEMICAL- MECHANICAL POLISHING SLURRIES
Singapore	200207263-5	April 2, 2001	READY-TO-USE STABLE CHEMICAL- MECHANICAL POLISHING SLURRIES
Taiwan	90113232	May 31, 2001	READY-TO-USE STABLE CHEMICAL- MECHANICAL POLISHING SLURRIES

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READY-TO-USE STABLE CHEMICAL- MECHANICAL POLISHING SLURRIES	A CONTINUOUS CHEMICAL MECHANICAL POLISHING PROCESS FOR POLISHING MULTIPLE CONDUCTIVE AND NON-CONDUCTIVE LAYERS ON SEMICONDUCTOR WAFERS	Title	READY-TO-USE STABLE CHEMICAL- MECHANICAL POLISHING SLURRIES
April 2, 2001	October 28, 2002	Issue Date	October 22, 2002
PCT/US01/10491	10/281,905	Patent No.	6,468,913
PCT	Sn	Country	Sn

RECORDED: 01/20/2004

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